

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 6,911,399 B2
DATED : September 19, 2003
INVENTOR(S) : Wei Liu and David Mui

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 2.

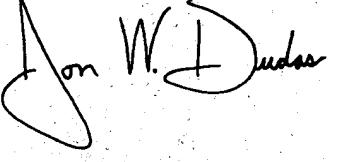
Line 15, change "to leave" to -- gas mixture to etch --.
Line 39, change "integrate" to -- integrated --.

Column 8.

Line 7, change "claim 3" to -- claim 1 --.
Line 14, change "scorn" to -- sccm --.

Signed and Sealed this

Eleventh Day of April, 2006



JON W. DUDAS
Director of the United States Patent and Trademark Office